

Information Disclosure
Statement By Applicant

(Use Several Sheets if Necessary)

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 Inventor: [redacted], et al
 Group: 2151 2653
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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
<i>DW</i>	A	4,408,189	Oct. 4, 1983	Betts et al	340	347	May 18, 1981
<i>DW</i>	B	4,888,779	Dec 19, 1989	Karabed, et al	371	43	Mar. 18, 1988
<i>DW</i>	C	5,257,272	Oct 26, 1993	Fredrickson	371	43	Apr 15, 1992
<i>DW</i>	D	5,331,320	Jul 19, 1994	Cideciyan, et al	341	56	Nov. 16, 1992
<i>DW</i>	E	5,375,249	Dec 20, 1994	Cho	395	800	Dec 28, 1990
<i>DW</i>	F	5,497,384	Mar 5, 1996	Fredrickson, et al	371	43	Dec 29, 1993
<i>DW</i>	G	5,537,382	Jul 16, 1996	McLaughlin, et al	369	116	Nov. 22, 1994
<i>DW</i>	H	5,748,119	May 5, 1998	Ko	341	59	Sep 18, 1996
<i>DW</i>	I	5,781,130	Jul 14, 1998	McLaughlin, et al	341	56	May 12, 1995
<i>DW</i>	J	5,790,571	Aug 4, 1998	Varanasi, Chandra	371	40.12	Dec 11, 1995
<i>DW</i>	K	5,818,806	Oct 6, 1998	Wong, et al	369	59	May 6, 1997
<i>DW</i>	L	5,828,754	Oct 27, 1998	Hogan	380	49	Jun 27, 1997
<i>DW</i>	M	5,854,779	Dec 29, 1998	Johnson, et al	369	59	Jan 5, 1996
<i>DW</i>	N	6,023,234	Feb. 8, 2000	Fukuoka	341	58	Feb 22, 1996

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
	L							
	O							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
<i>DW</i>	P	"Magnetoresistive Heads and Partial Response Maximum Likelihood Read Channels Technology Overview", http://www.andatco.com/genesis_s/segment1/techinfo/white_papers/mrhead/mrhead.html , 2/3/99
<i>DW</i>	S	Taratorin, Alex, "Characterization of Magnetic Recording Systems: A Practical Approach", Chapter 9, "Introduction to PRML", http://www.guzik.com/Chapter9.htm , 2/3/99.
Examiner	Huber, Paul	
	Date Considered 9/13/04	

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.